

## First Experimental Evidence for the Formation of a Silicate Anion by Intramolecular Addition of a Persulfoxide to a Trimethylsiloxy Group.

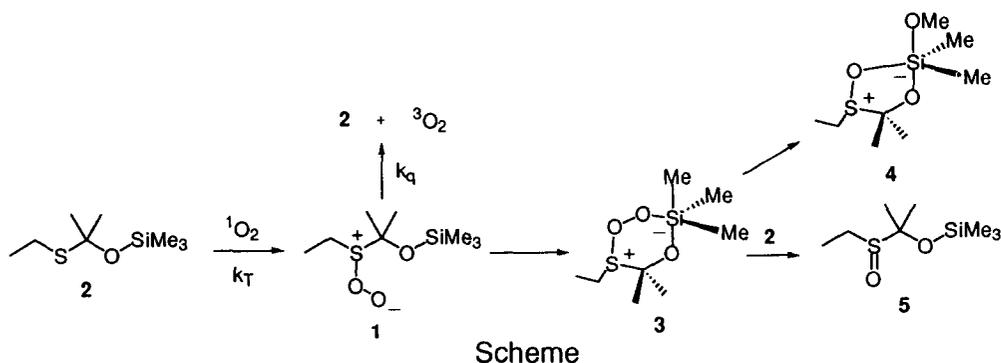
Edward L. Clennan,\* David L. Dillon

Department of Chemistry  
University of Wyoming  
Laramie WY 82071

Received 21 May 1998; revised 26 June 1998; accepted 10 July 1998

**Abstract:** The photooxidation of an  $\alpha$ -trimethylsiloxy sulfide has been studied. The reaction generates a persulfoxide which can be trapped by diphenylsulfide, decompose to generate triplet oxygen and substrate, or rearrange to a silicate product via a silicate intermediate. © 1998 Elsevier Science Ltd. All rights reserved.

Persulfoxides, (e.g. **1** in the Scheme), were first suggested as discrete bound species by Schenck and Krausch<sup>1</sup> during their pioneering study of the photooxidations of dialkyl sulfides. Subsequent computational<sup>2</sup> and experimental studies<sup>3,4</sup> have verified this suggestion and have provided compelling evidence that **1** is a ubiquitous intermediate in the reactions of singlet oxygen with a wide range of organosulfur compounds.<sup>5-7</sup> Persulfoxides have never been directly observed at room temperature as a result of the availability of several facile inter- and intramolecular reaction pathways.<sup>7-12</sup> We now report that the photooxidation of [1-(ethylthio)-1-methylethoxy]trimethylsilane, **2**, provides the first compelling evidence for the formation of silicate intermediate, **3**, and silicate product **4**, via a persulfoxide as depicted in the following Scheme.



Irradiation of an oxygen saturated 0.012 M solution of **2**, 0.3 M pyridine, and  $1 \times 10^{-4}$  M tetraphenylporphyrin (TPP), in toluene- $d_6$  at  $-60^\circ\text{C}$  for 20 minutes through 1cm of a saturated sodium nitrite

filter solution resulted in the complete disappearance of **2**, formation of acetone, a trace of diethyldisulfide, several unidentified products, and **4** as the major product. Conspicuously absent were the sulfoxide **5** and the corresponding sulfone. Participation of singlet oxygen in these reactions was verified by demonstrating that **2** quenched the emission of  $^1\text{O}_2$  at 1270nm, that  $5 \times 10^{-3}$  M DABCO completely quenched the reaction, and that the rate of the reaction was much faster in toluene- $d_8$  than in toluene- $h_8$ .

In order to verify the absence of either sulfoxide **5** or the corresponding sulfone, **6**, they were independently synthesized by treatment of **2** at  $-60^\circ\text{C}$  with one or two equivalents of MCPBA in the presence of pyridine, respectively. Their structures were verified by both low temperature  $^1\text{H}$  and  $^{13}\text{C}$  NMR. [**5**  $^1\text{H}$  NMR (toluene- $d_8$ )  $\delta$  0.06(s, 9H), 1.15(t,  $J = 7\text{Hz}$ , 3H), 1.29(s, 3H), 1.30(s, 3H), 2.15(m, 1H), 2.24(m, 1H),  $^{13}\text{C}$  NMR ( $\text{CDCl}_3$ )  $\delta$  2.0, 8.3, 20.7, 26.0, 38.6, 88.2; **6**  $^1\text{H}$  NMR (toluene- $d_8$ )  $\delta$  0.10(s, 9H), 1.10(t,  $J = 7\text{Hz}$ , 3H), 1.34(s, 6H), 2.42(q,  $J = 7\text{Hz}$ , 2H),  $^{13}\text{C}$  NMR ( $\text{CDCl}_3$ )  $\delta$  1.9, 5.3, 23.7, 39.0, 92.0]. Sulfoxide, **5**, decomposes at temperatures at or above  $-20^\circ\text{C}$  in a clean first order process with activation barriers at the 95% confidence level of  $\Delta H^\ddagger = 19.6 \pm 2.3$  kcal/mol,  $\Delta S^\ddagger = -6 \pm 8$  cal mol $^{-1}$  K $^{-1}$ , and  $\Delta G^\ddagger(298.16) = 21.3 \pm 4.6$  kcal/mol.

The identity of silicate **4** was established by a combination of  $^1\text{H}$  NMR,  $^{13}\text{C}$  NMR, DEPT, and C,H-COSY experiments (Figure 1). The observation of a methoxy peak at 3.27 ppm in the proton NMR which correlated to a methyl peak at 49.7 ppm in the  $^{13}\text{C}$  NMR was especially revealing. In addition, the observation of overlapping gem-dimethyl groups in the  $^1\text{H}$  NMR which are well separated in the  $^{13}\text{C}$  NMR, two very closely spaced Si-Me groups in the  $^1\text{H}$  and  $^{13}\text{C}$  NMR's, and a quaternary carbon at 88.0 ppm in the  $^{13}\text{C}$  NMR, are compelling evidence for the structure of **4**.

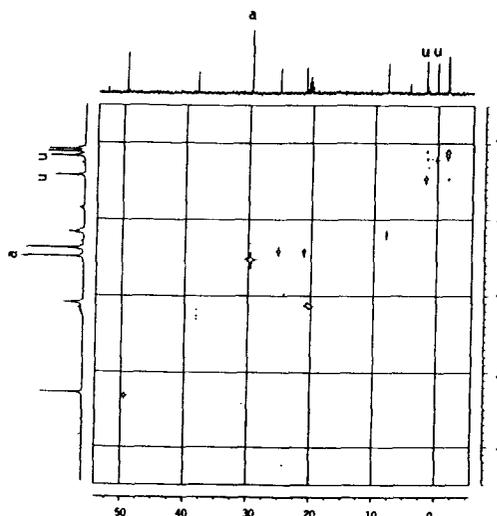


FIGURE 1. C,H - COSY of the reaction mixture from photooxidation of **2** at  $-60^\circ\text{C}$  in toluene- $d_8$ . a-acetone; u-unknown

Two intermediates formed prior to the silicate, **4**, are also required by the following experimental evidence. Incrementally increasing the concentration of **2** in this experiment from 0.002 molar to 0.3 molar, resulted in the appearance and increase of sulfoxide **5**. However, silicate **4** is unreactive towards **2** as demonstrated by addition of authentically prepared **2** at the end of the photooxidation. Consequently, a fleeting intermediate trapped by **2** must have been intercepted. We suggest that this trapped intermediate is silicate **3**. The peroxide unit in silicate **3** is likely to be susceptible to nucleophilic attack by **2** and its rearrangement by migration of an apical methyl group to form **4** has ample precedent in migrations from silicon to carbon.<sup>13</sup> Increasing the concentration of **2** from 0.01 to 0.50 M had no effect on the extent of non productive physical quenching. (i.e. **2** does not trap an intermediate which dissociates to starting material and <sup>3</sup>O<sub>2</sub> since this would increase the efficiency of the reaction)<sup>2</sup> The extent of physical quenching was determined by comparing the rate constant for chemical reaction of **2**,  $k_r$ , which was measured by NMR in CDCl<sub>3</sub> in competition with tetramethylethylene using the method of Higgins, Foote, and Cheng,<sup>14</sup> to the rate constant for disappearance of singlet oxygen,  $k_T$ , which was measured by examining the ability of **2** to quench the time-resolved emission of singlet oxygen at 1270 nm as described earlier.<sup>15</sup> The ratio  $k_r/k_T = [(1.46 \pm 0.62) \times 10^6 \text{M}^{-1}\text{s}^{-1}]/[(2.67 \pm 0.30) \times 10^6 \text{M}^{-1}\text{s}^{-1}]$  reveals that  $k_r$  is only 55% of  $k_T$  and is independent of concentration. Consequently, nonproductive physical quenching must account for 45% of all interactions of singlet oxygen with **2** over the entire range of 0.01 to 0.50M. Considerable precedent exists which suggests that it is decomposition of a persulfoxide ( $k_q$  in the Scheme) which is responsible for the inefficiency of sulfide photooxidations.<sup>2,3</sup>

Additional evidence for the persulfoxide was obtained by cophotooxidation of **2** and diphenylsulfoxide (Ph<sub>2</sub>SO). An intermediate is implicated since Ph<sub>2</sub>SO is unreactive in the absence of **2**, but is converted to diphenylsulfone (Ph<sub>2</sub>SO<sub>2</sub>) when cophotooxidized with **2**. In addition, bis-(p-chlorophenyl)sulfoxide, (pClPh)<sub>2</sub>SO, is approximately 3 times more reactive than Ph<sub>2</sub>SO consistent with the nucleophilic character of the persulfoxide but inconsistent with the anticipated electrophilic character of **3**.

The persulfoxide in the reaction of **2** was 10 times more difficult to trap than the persulfoxide formed in the photooxidation of diethylsulfide. In addition, physical quenching accounts for 95% of the interactions of singlet oxygen with diethylsulfide but only 45% of the interactions with **2**. Both these observations point to a reduced lifetime of the persulfoxide formed in the reaction of **2** in comparison to diethylpersulfoxide. This suggests that formation of **3** is considerably more rapid than formation of the putative second intermediate in diethylsulfide photooxidation.

In conclusion, the photooxidations of appropriately substituted sulfides can now be added to a growing list of reactions which have been demonstrated to proceed via hypervalent silicon intermediates.<sup>16</sup> In addition, the formation of **4** and the absence of rearrangement of **5** to its silicate isomer reveals a remarkable stabilization of the trigonal bipyramidal structure by the apocophilic methoxy group.

**Acknowledgment:** We thank the National Science Foundation and the donors of the Petroleum Research Fund, administered by the American Chemical Society, for their generous support of this research.

### References

1. Schenck, G. O.; Krausch, C. H. *Angew. Chem.* **1962**, *74*, 510.
2. Jensen, F. In *Advances in Oxygenated Processes*; A. L. Baumstark, Ed.; JAI Press: Greenwich, CT, 1995; Vol. 4; pp 1-48.
3. Clennan, E. L. In *Advances in Oxygenated Processes*; A. L. Baumstark, Ed.; JAI Press: Greenwich, CT., 1995; Vol. IV; pp 49-80.
4. Ando, W.; Kabe, Y.; Kobayashi, S.; Takyu, C.; Yamagishi, A.; Inaba, H. *J. Am. Chem. Soc.* **1980**, *102*, 4526-4528.
5. Clennan, E. L.; Zhang, H. *J. Am. Chem. Soc.* **1994**, *116*, 809-810.
6. Clennan, E. L.; Chen, M.-F. *J. Org. Chem.* **1995**, *60*, 6444-6447.
7. Liang, J.-J.; Gu, C.-L.; Kacher, M. L.; Foote, C. S. *J. Am. Chem. Soc.* **1983**, *105*, 4717-4721.
8. Clennan, E. L.; Yang, K. *J. Am. Chem. Soc.* **1990**, *112*, 4044-4046.
9. Clennan, E. L.; Yang, K. *J. Org. Chem.* **1992**, *57*, 4477-4487.
10. Corey, E. J.; Ouannes, C. *Tetrahedron Lett.* **1976**, 4263-4266.
11. Foote, C. S.; Denny, R. W.; Weaver, L.; Chang, Y. *Ann. N.Y. Acad. Sci.* **1970**, *171*, 139-148.
12. Bhardwaj, R. K.; Davidson, R. S. *Tetrahedron* **1987**, *43*, 4473-4479.
13. Hijji, Y. M.; Hudrlik, P. F.; Hudrlik, A. M. *J. Chem. Soc. Chem. Commun.* **1998**, 1213-1214.
14. Higgins, R.; Foote, C. S.; Cheng, H. In *Advances in Chemistry Series*; R. F. Gould, Ed.; American Chemical Society: Washington D. C., 1968; Vol. 77; pp 102-117.
15. Clennan, E. L.; Noe, L. J.; Szneler, E.; Wen, T. *J. Am. Chem. Soc.* **1990**, *112*, 5080-5085.
16. Denmark, S. E.; Griedel, B. D.; Coe, D. M.; Schnute, M. E. *J. Am. Chem. Soc.* **1994**, *116*, 7026-7043.